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Emission of Terahertz Radiation from Two-Dimensional Electron Systems in Semiconductor Nano-Heterostructures

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ABSTRACT

This paper reviews recent advances in emission of terahertz radiation from two-dimensional (2D) electron systems in semiconductor nano-heterostructures. 2D plasmon resonance is first presented to demonstrate intense broadband terahertz emission from InGaP/InGaAs/GaAs material systems. The device structure is based on a high-electron mobility transistor and incorporates the author's original interdigitated dual-grating gates. Second topic focuses on graphene, a monolayer carbon-atomic honeycomb lattice crystal, exhibiting unique carrier transport and optical properties owing to massless and gapless energy spectrum. Coherent stimulated terahertz emission from femtosecond infrared-laser pumped epitaxial graphene is experimentally observed, reflecting the occurrence of negative dynamic conductivity and population inversion.

Keywords: Terahertz emission; Two-dimensional electrons; plasmons; graphene; heterostructures

1. INTRODUCTION

In the research of modern terahertz (THz) electronics, development of compact, tunable and coherent sources operating at THz frequencies is one of the hottest issues [1]. Two-dimensional (2D) plasmons in semiconductor nano-hetero-structures like electron channels in high-electron mobility transistors (HEMT's) have attracted much attention due to their nature of promoting emission of electromagnetic radiation in the THz range. Therefore different devices/structures of micron and submicron sizes supporting low-dimensional plasmons were intensively studied as possible candidates for solid-state far-infrared (FIR)/THz sources [1–16]. Mechanisms of plasma wave excitation/emission can be divided (by convention) into two types: (i) incoherent and (ii) coherent type. The first is related to thermal excitation of broadband nonresonant plasmons by hot electrons [2–7]. The second is related to the plasma wave instability mechanisms like Dyakonov–Shur Doppler-shift model [8, 16] and/or Ryzhii-Satou-Shur transit-time model [17, 18], where coherent plasmons can be excited either by hot electrons or by optical phonon emission under near ballistic electron motion [19].

On the other hand, graphene, a monolayer of carbon atoms in a honeycomb lattice crystal, has attracted considerable attention due to its unique carrier transport and optical properties, including massless and gapless energy spectra [20-22]. The gapless and linear energy spectra of electrons and holes lead to nontrivial features such as negative dynamic conductivity. Ryzhii et al. analytically revealed that optically pumped graphene can exhibit negative-dynamic conductivity in the THz spectral range [23, 24] which may lead to the development of a new type of THz laser [25, 26].

To realize such graphene-based devices, understanding the non-equilibrium carrier relaxation/recombination dynamics is critical. Ultrafast scattering of photoexcited carriers by optical phonons has been theoretically predicted [27-29]. Recently, time-resolved measurements of fast non-equilibrium carrier relaxation dynamics have been carried out for multilayers and

monolayers of graphene that were epitaxially grown on SiC [30-34] and exfoliated from highly oriented pyrolytic graphite (HOPG) [35, 36]. For the electron-hole recombination, radiative recombination via direct-transition may take place due to the gapless symmetrical band structure. Photon emissions over a wide THz frequency range are expected if the pumping photon energy is suitably chosen and the pumping intensity is sufficiently high. This may lead to the above-mentioned laser operation if the graphene is accommodated in a high quality factor cavity. This paper reviews recent advances in emission of terahertz radiation from 2D electron systems in III-V HEMT's and graphene semiconductor nano-heterostructures.

2. THz Emission from 2D Plasmon Resonance

2.1. Device Structure and Performance

We are proposing our original 2D-plasmon-resonant micro-chip emitter as a new terahertz light source [37-42]. Figure 1 illustrates the cross section of the plasmon-resonant emitter [37]. The device structure is based on a HEMT and incorporates (i) interdigitated dual-grating gates (G1 and G2) that periodically localize the 2D plasmon in stripes on the order of 100 nm with a micron-to-submicron interval and (ii) a vertical cavity structure in between the top grating plane and a THz mirror at the backside. The structure (i) works as a THz antenna and (ii) works as an amplifier.

When the DC drain-to-source bias V_{DS} is applied, 2D electrons are accelerated to produce a constant drain-to-source current I_{DS} . Due to such a distributed plasmonic cavity systems in periodic 2D electron-density modulation, the DC current flow may excite the plasma waves in each plasmonic cavity. As shown in Fig. 2, asymmetric cavity boundaries make plasma-wave reflections as well as fractions in the density and the drift velocity of electrons, which may cause the current-driven plasmon instability [8, 12, 17, 18] leading to excitation of coherent resonant plasmons. Thermally excited hot electrons also may excite incoherent plasmons [4, 7, 40]. The

grating gates act also as THz antenna that converts non-radiative longitudinal plasmon modes to radiative transverse electromagnetic modes [2, 3, 6, 12, 37].

Once the THz electromagnetic waves are produced from the seed of plasma waves, downward-propagating electromagnetic waves are reflected at the mirror back to the plasmon region so that the reflected waves can directly excite the plasmon again according to the Drude optical conductivity [37]. When the plasmon resonant frequency satisfies the standing-wave condition of the vertical cavity, the THz electromagnetic radiation will reinforce the plasmon resonance in a recursive manner. Therefore, the vertical cavity may work as an amplifier of THz radiation if the gain exceeds the cavity loss. The quality factor of the vertical cavity is relatively low, but as simulated in [37], it can serve as a broadband response amplifier.

The experimentally investigated device was fabricated with InGaP/InGaAs/GaAs material systems in a double-deck HEMT with semiconducting 2D electron gas (2DEG) grating gates [41, 42]. The schematic device cross section and its SEM image are shown in Fig. 3. The 2D plasmon layer was formed with a lower-deck quantum well at the heterointerface between a 15-nm thick InGaAs channel layer and a 60-nm thick, InGaP carrier-supplying layer. The upper-deck InGaAs channel, was serving as the dual grating-gate electrodes. It was periodically etched to form the uncapped region where the 2DEG concentration becomes lower than the capped region modulating the carrier density in this way without any external gate bias. For the source/drain ohmic contacts, AuGe/Ni was lifted off and annealed after the upper-deck HEMT was selectively etched. The intrinsic device area has geometry of 30 µm x75 µm, where the grating pattern is replicated on the upper-deck HEMT layer. The grating consisted of 150-nm lines and 1850-nm lines aligned alternately with a spacing of 100 nm. The number of fingers was 37 (38) for the 1500-nm (1850-nm) grating. The substrate thickness was 260 µm, corresponding to the fundamental vertical cavity resonance of 80 GHz and the odd harmonics with a 160-GHz spacing.

The field emission property of the fabricated chip was characterized by using a Fouriertransformed far-infrared spectrometer (FTIR) [42]. The microchip emitter die was mounted on a quartz substrate. The contact pads on the die were electrically interconnected to the biasing metal lines patterned on the substrate via gold bonding wires. The substrate was attached into a dedicated sample holder. Then the sample holder was installed into the FTIR source chamber. The electromagnetic radiation from the device was introduced to the Martin-Pupplett interferometer room and led to a liquid-He cooled Si bolometer. The responsivity and noiseequivalent power (NEP) of the detector were 2.84x10⁵ V/W⁻¹ and 1.16x10⁻¹³ W/Hz^{-1/2}, respectively. The experimental procedure was as follows; first the background radiation under turning-off the device was measured, then the radiation with device turned on was measured. The spectrum of the first-step measurement contained the 300K blackbody radiation modified by the spectral functions of all the elements inside the chamber. Thus, in order to extract the contents of the real emission by the active operation of the device, the spectrum of the second-step measurement was normalized to the first-step one.

As shown in Fig. 4(a), the device was emitting 0.5-to-6.5 THz radiation at 300K under appropriate bias conditions. The maximum emission power at $V_{\text{DS}} = 12.0$ V was estimated to be of the order of 1 μ W at 300K. Taking into account the monitored power consumption of the order of 100 mW, the energy conversion efficiency (from DC to THz) was estimated to be of the order of 10⁻⁵. Such a broadband emission with threshold/super-linear dependence on the drain bias is analytically interpreted as the excitation of multimode plasmons: thermal excitation of incoherent plasmons [2, 43] as well as coherent plasmons related to instability-driven and/or transit-time-driven self-excitation [8, 44]. We attribute the fine spectral structure to longitudinal-mode-like vibrations due to substrate-induced Fabry-Perot modes. The substrate thickness of 260 μ m gives the longitudinal modes (odd harmonics) in a 160-GHz distance, which perfectly coincides with

the observed periodicity of the fine spectral modes. Since the plasmonic cavity must have high emissivity of its main role, the reflection coefficient of the plasmonic plane is relatively low. This results in an insufficient quality factor of the vertical cavity, leading to such a broadband emission. Coherent monochromatic emission can be realized by engineering/accommodating high-Q cavity and/or by injection locking of the resonant frequency that can be produced for example by the photomixing of two infrared/visible lasers [45].

The emission spectral profile of the fabricated device was compared to that of a standard water-cooled high-pressure mercury lamp used as a standard THz light source in FTIR systems. Fig 4(a) plots the typical results [42]. It is clearly seen that the main lobe of the emission spectra of the fabricated device stays around 1 to 6 THz. The emission spectrum of the mercury lamp traces the typical black-body radiation curve. Its emission weakens substantially at lower THz region.

Emission power intensity of the mercury lamp in the THz region of our interest is about 30 times higher than that for a single-chip plasmon emitter at the sacrifice of huge power consumption (three orders of magnitude higher than that for a single-chip HEMT emitter). It is possible for the plasmon emitters to easily boost the emission power by orders of magnitude with reasonable power consumption by implementing in an arrayed structure. Preliminary trial of multi-chip operation was carried out [42]. The wire-bonded two independent emitters fabricated on a single wafer were electrically biased at Vds = 9.0 V to operate simultaneously. Figure 4(b) demonstrates that the dual-chip operations can almost double the emission intensity. It is also worth to note that the plasmon emitter device may operate without any water cooling facility. From the above investigation, the plasmon-resonant emitter has a competitive potentiality to replace the standard Hg lamp sources in the THz spectroscopic measurement.

2.2. Application to THz Spectroscopy

The fabricated sample was introduced to a FTIR system as a 'microchip' THz source and used in a few standard spectroscopy tests. Water-vapor absorption spectrum was successfully observed at 300K, and compared to the standard data provided by NASA (see Fig. 5) [42]. Also the transmission spectra of two different types of sugar groups were measured: honey and maple syrup, both of which contain their finger prints in the THz region. The measured spectra were compared with the results of the data base of RIKEN (see Fig. 6). The results exhibit fairly identical spectral features confirming potential of the HEMTs plasma sources [42].

The results using a standard high-pressure mercury lamp as the light source are also plotted in Fig. 6. Due to its intense emission (by one order of magnitude higher than that for the single microchip emitter), excellent S/N is obtained. Preliminary trial of dual chip operation of the microchip emitter successfully doubles the output intensity over the emission band [42]. Thus, we predict that an arrayed integration of the emitter can improve the emission intensity by orders of magnitude. To the best of the authors' knowledge, this is the first-time demonstration of THz sensing/spectroscopic applications utilizing room-temperature operating THz semiconductor microscopic light emitters. Future improvements of the emission power may enable this device to be a candidate as a new THz light source competing with standard black body radiation based ones.

3. Stimulated THz Emission from Optically-Pumped Graphene

3.1. Carrier Dynamics of Optically Pumped Graphene

When graphene is pumped with photon energy $\hbar\Omega$, electrons and holes are photogenerated via interband transitions. Figure 7 presents the carrier relaxation/recombination processes and the non-equilibrium energy distributions of photoelectrons/photoholes at specific times from ~10 fs to few picoseconds after the pumping event [23]. Usually photoexcited carriers are first cooled and thermalized mainly by intraband relaxation processes on femtosecond to subpicosecond time

scales, and then by interband recombination processes. A recent study by Breusing et al. [36] precisely revealed ultrafast carrier dynamics for exfoliated graphene and graphite with a time resolution as low as 10 fs. It has been shown that the intraband carrier equilibration in optically excited graphene (with pumping photon energy $\hbar\Omega$) first establishes separate quasi-equilibrium distributions of electrons and holes at around the level $\varepsilon_f \pm \hbar \Omega/2$ (ε_f : Fermi energy) within 20-30 fs after excitation (see Fig. 7(b)), followed by cooling of these electrons and holes by emission of a cascade (N times) of optical phonons ($\hbar\omega_0$) within 200 fs time scale. After this process these electrons and holes occupy the states $\varepsilon_f \pm \varepsilon_N \approx \varepsilon_f \pm \hbar(\Omega/2 - N\omega_0)$, $\varepsilon_N < \hbar\omega_0$ (see Fig. 7(c)). Then, thermalization can occur via electron-hole recombination as well as intraband Fermization due to carrier-carrier (cc) scattering and carrier-phonon (cp) scattering (as shown with energy $\hbar\omega_a$ in Fig. 7(a)). This happens on a picosecond time scale (see Fig. 7(d)), because the interband cc scattering and cp scattering are slowed by the density of states effects and Pauli blocking. As a consequence, photoelectrons/holes recombine to radiate THz photons with the energy $\hbar \omega \approx 2\varepsilon_N$ as shown in Fig. 7(a) [23].

Let us consider the THz optical conductivity due to such a relaxation/recombination processes responsible for the carriers staying at $\varepsilon_f \pm \hbar \omega/2$. The electron and hole distribution functions at the Dirac point are $f_e(0) = f_h(0) = 1/2$. This implies that at even weak photoexcitation, the values of the distribution functions at low energies ε can be $f_e(\varepsilon) = f_h(\varepsilon) > 1/2$, that corresponds to the population inversion [23]. Such a population inversion might lead to the interband transitions related negative ac conductivity at THz frequencies. However, the intraband processes determined by the Drude conductivity provide the positive contribution to the ac conductivity. One might expect that under sufficiently strong optical excitation resulting in photogeneration of electron-hole pairs, total ac conductivity becomes "negative". The real part of the net *ac* conductivity Re σ_{ω} is proportional to the absorption of photons with frequency ω and comprises the contributions of both interband and intraband transitions [23],

Re
$$\sigma_{\omega}$$
 = Re σ_{ω}^{inter} + Re σ_{ω}^{intra} .

Let us assume a relatively weak optical excitation: $\varepsilon_F < k_B T$, where ε_F the non-equilibrium quasi-Fermi energy and $k_B T$ the thermal energy. In this case, for the THz frequencies $\omega < 2k_B T / \hbar$, Re σ_{ω}^{inter} can be presented as

Re
$$\sigma_{\omega}^{inter} = \frac{e^2}{4\hbar} \left[1 - f_e \left(\frac{\hbar \omega}{2} \right) - f_h \left(\frac{\hbar \omega}{2} \right) \right] \approx \frac{e^2}{8\hbar} \left(\frac{\hbar \omega}{2k_B T} - \eta_F \right),$$

where *e* the elementary charge, $\eta_F \equiv \varepsilon_F / k_B T$ the normalized quasi-Fermi energy [23]. On the other hand, Re σ_{ω}^{intra} can be presented as

Re
$$\sigma_{\omega}^{intra} \approx \frac{(\ln 2 + \eta_F / 2)e^2}{\pi \hbar} \frac{T\tau}{\hbar (1 + \omega^2 \tau^2)},$$

where τ the momentum relaxation time of electrons/holes [23]. Since η_F corresponds to the ratio of the excess electron/hole concentration δn (equivalent to photoelectron/photohole concentration) to the thermally equilibrium electron/hole concentration n_0 , η_F is given by

$$\eta_F = \frac{\delta n}{n_0} = \frac{\tau_R \alpha_\Omega I_\Omega}{n_0} \approx \frac{12e^2}{\hbar c} \left(\frac{\hbar v_F}{k_B T}\right)^2 \frac{\tau_R I_\Omega}{\hbar \Omega},$$

where τ_R electron/hole recombination time, α_{Ω} the interband absorption coefficient, I_{Ω} the pumping intensity, *c* the speed of light, v_F the Fermi velocity [23].

As a consequence, Re σ_{ω} becomes

$$\begin{split} & \operatorname{Re} \ \sigma_{\omega} \approx \frac{e^2}{8\hbar} \Biggl[\frac{\hbar\omega}{2k_BT} + \frac{8\ln 2}{\pi} \frac{k_BT\tau}{\hbar(1+\omega^2\tau^2)} - \frac{12e^2}{\hbar c} \Biggl(\frac{\hbar v_F}{k_BT} \Biggr)^2 \frac{\tau_R I_\Omega}{\hbar\Omega} \Biggr] \\ &= \frac{e^2 \overline{g}}{8\hbar} \Biggl[1 + \frac{3}{2} \Biggl(\frac{\omega - \overline{\omega}}{\overline{\omega}} \Biggr)^2 - \frac{I_\Omega}{\overline{I_\Omega}} \Biggr], \end{split}$$

where

$$\overline{\omega} \approx \left(\frac{k_B T \tau}{\hbar}\right)^{2/3} \frac{1.92}{\tau}, \ \overline{I_{\Omega}} \approx 11 \left(\frac{\hbar}{k_B T \tau}\right)^{1/3} \left(\frac{k_B T}{\hbar v_F}\right)^2 \frac{\hbar \Omega}{\tau_R}.$$

When the pumping intensity exceeds the threshold: $I_{\Omega} > \overline{I_{\Omega}}$, Re σ_{ω} becomes negative in a certain range around $\overline{\omega}$. When T = 300K, $\tau = 10^{-12}$ s, $\tau_R = 10^{-9} \square 10^{-11}$ s, $\overline{I_{\Omega}} \approx 60 \sim 6000$ W/cm². Assuming the device size of 100 µm × 100 µm, we find that the required pumping intensity, which provides the negative dynamic conductivity, $\overline{I_{\Omega}} \approx 6 \sim 600$ mW.

Fig. 8 plots the calculated Re σ_{ω} for various pumping intensities when T = 300K, $\tau = 10^{-12}$ s, and $\tau_R = 10^{-9}$ s. The vertical scale is normalized to the characteristic conductivity $e^2/2\hbar$. It is clearly seen that the frequency range where the conductivity becomes negative widens with pumping intensity.

3.2. Observation of Stimulated THz Emission

In order to verify the proposed concept, we conduct an experimental study on the electromagnetic radiation emitted from an optically pumped graphene structure using THz emission spectroscopy [46]. The sample used in this experiment is heteroepitaxial graphene film grown on a SiC(110) thin film heteroepitaxially grown on a Si(110) substrate via thermal graphitization of the SiC surface [47-49]. In the Raman spectrum of the graphene film, the principal bands of graphene, namely, the G (1595 cm⁻¹) and G' (2730 cm⁻¹) bands, are observed

as shown in Fig. 9. Furthermore, as is shown in Fig. 9, transmission electron microscopy images indicate that the film is stratified. It is thus concluded that epitaxial graphene with a planar structure can be produced by this fabrication method. Furthermore, the epitaxial graphene layer is inferred to have a non-Bernal stacking arrangement because the G' band in the Raman spectrum can be expressed as a single component related to the two-dimensionality of the graphene film [50, 51]. The non-Bernal stacked epitaxial graphene layers grown by our method can be treated as a set of isolated single graphene layers, as in the case of an epitaxial graphene layer on a C-terminated SiC bulk crystal [52]. The G-band peak at 1595 cm⁻¹ corresponds to an optical phonon energy at the zone center of 197.8 meV.

We measure the carrier relaxation and recombination dynamics in optically pumped epitaxial graphene-on-silicon (GOS) heterostructures using THz time-domain spectroscopy based on an optical pump/THz-and-optical-probe technique. The time-resolved field emission properties are measured by an electro-optic sampling method in total-reflection geometry [53]. To obtain the THz photon emissions from the above-mentioned carrier relaxation/recombination dynamics, the pumping photon energy (wavelength) is carefully selected to be around 800 meV (1550 nm). To perform intense pumping beyond the threshold, a femtosecond pulsed fiber laser with full width at half-maximum (FWHM) of 80 fs, pulse energy of 50 pJ/pulse, and frequency of 20 MHz was used as the pumping source. The setup is shown in Fig. 10. The graphene sample is placed on the stage and a 100-µm-thick (101)-oriented CdTe crystal is placed onto the sample; the CdTe crystal acts as a THz probe pulse emitter as well as an electro-optic sensor. The single femtosecond fiber laser beam is split into two beams; one for optical pumping and generating the THz probe beam. and one for optical probing. The pumping laser, which is linearly polarized and mechanically chopped at ~1.2 KHz, is simultaneously focused at normal incidence onto the sample and the CdTe from below, while the probing laser, which is cross-polarized to the pumping beam, is focused from above. The incident pumping beam is defocused on the sample to satisfy the above-

mentioned pumping power requirements. The resulting photoexcited carrier density is ~ 8×10^{10} cm⁻², which is comparable to the background carrier density. Owing to second-order nonlinear optical effects, the CdTe crystal can rectify the pumping laser pulse to emit THz envelope radiation. Such THz pulses irradiate the graphene sample, acting as THz probe signals to stimulate THz photon emission via electron-hole recombination in the GOS. Due to the geometrical situation of the experimental setup as shown in Fig. 10, the time delay of the THz probe with respect to optical pumping is fixed at around 200-300 fs so that the photoelectrons/holes are stimulated immediately after losing their energy via the cascade of optical phonon emissions, when they still have a distribution of $\varepsilon_f \pm \varepsilon_N$ (as is shown in Fig. 7(c)). On the other hand, through the Si prism attached to the CdTe crystal, the optical probing beam is totally reflected back to the lock-in detection block, and its phase information reflecting the electric field intensity is lock-in amplified. By sweeping the timing of the optical probe using an optical delay line, the whole temporal profile of the field emission properties can be obtained. The system bandwidth is estimated to be around 6 THz, which is limited mainly by the Reststrahlen band of the CdTe sensor crystal.

Figure 11 shows the autocorrelations and spectral profiles of the pumping laser beams under two different pulse compression conditions. The horizontal axis indicates the wavelength and frequency together with the estimated THz photon frequency to be emitted from the sample. The dotted line plots the dynamic conductivity at a pumping intensity twice as high as the threshold intensity calculated for 300 K using Eqs. (1)-(3) with a τ value of 1×10⁻¹² ps. The shaded area shows the negative dynamic conductivity.

First, the experiment was conducted with the pumping pulse shown in Fig. 11 as red lines. Figure 12(a) shows the measured results. The emission from the CdTe without graphene exhibits a temporal response similar to optical rectification with a single peak at around 1 THz and an upper weak side lobe extending to around 7 THz (blue lines in Fig. 12). On the other hand, the results with graphene agree well with the pumping photon spectrum and include an additional peak around 1 THz from the original CdTe spectrum (red lines in Fig. 12). It is thought that the THz emissions from graphene are stimulated by the coherent THz probe radiation that originates from the CdTe excited by the pump laser beam. The THz emissions are amplified by photoelectron/hole recombination in the range of the negative dynamic conductivity.

In order to confirm with certainty that the emissions from graphene reflect the pumping photon spectrum, the pulse compression of the pumping laser pulse was altered to broaden its spectrum as shown by the black lines in Fig. 11. Due to the pulse compression condition, the pulse energy increases ~100 pJ/pulse. As can be seen in Fig. 12(b), the emission spectrum of the graphene was broadened, corresponding to the pumping photon energy.

Furthermore, to confirm the effects of the THz probe, we replace the first CdTe crystal with another CdTe crystal having a high-reflectivity coating for IR on its bottom surface, in order to eliminate generation of the THz probe signal. In this case, no distinctive response is observed with or without graphene. Since the measurements are taken as an average, the observed response is undoubtedly a coherent process that cannot be obtained via spontaneous emission processes, providing clear evidence of stimulated emission. For all three cases of emissions from graphene in Figs. 12(a) and (b), the lower cutoff around 2 THz (8.3 meV) is slightly higher than the theoretical estimation (~5 meV) [23]. This may be due to a small bandgap forming due to the interlayer coupling of the existing multilayer graphene or substrate-induced asymmetric potential deformation [54].

From the above results, it is inferred that THz emissions from graphene are stimulated by the coherent THz probe radiation. Furthermore, the THz emissions are amplified via photoelectron/hole recombination in the range of the negative dynamic conductivity. In conclusion, we have successfully observed coherent amplified stimulated THz emissions arising

from the fast relaxation and relatively slow recombination dynamics of photogenerated electrons/holes in epitaxial graphene heterostructures. The results provide evidence of the occurrence of negative dynamic conductivity, which can potentially be applied to a new type of THz laser.

4. Conclusion

Recent advances in emission of terahertz radiation from 2D electron systems in semiconductor nano-heterostructures were reviewed. 2D plasmon resonance in HEMT structures as well as ultrafast non-equilibrium dynamics of massless electrons/ holes in graphene are promising mechanisms for making new types of practical THz solid-state light sources.

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Figure Captions

Fig. 1. Device cross section for typical GaAs-based heterostructure material systems. *Ex*: the electric field (linear polarization), k_{THz} : the wave vector of electromagnetic radiation. (after Ref. 37.)

Fig. 2. Schematic band diagram and operation mechanism.

Fig. 3. Cross sectional and bird's view images of a fabricated plasmon-resonant emitter. (after Ref. 41.) The die mounted on a quartz substrate is also shown in comparison with a commercial high-pressure mercury lamp.

Fig. 4. FTIR measured emission spectra for a fabricated device in comparison with a high-pressure mercury lamp. Double- and triple-chip operation almost doubles and triples the emission power, respectively. $V_{DS} = 9.0 \text{ V}$.

Fig. 5. Measured absorption spectrum of atmospheric water vapor in comparison with the data provided by NASA. (after Ref. 42.)

Fig. 6. Transmission spectra for sugar group samples. (a) Results for honey measured by using a single-chip plasmon-resonant emitter (PRE) and by using a high-pressure mercury lump, and their main ingredient(s) provided by RIKEN, (b) results for maple syrup measured by using sigle-and triple-chip PRE(s), and by using a high-pressure mercury lump.

Fig. 7. Schematic view of graphene band structure (a) and energy distributions of photogenerated electrons and holes (b)-(d). Arrows denote transitions corresponding to optical excitation by photons with energy $\hbar \Omega$, cascade emission of optical phonons with energy $\hbar \omega_0$, and radiative recombination with emission of photons with energy $\hbar \omega$. (b) after ~20 fs from optical pumping, (c) after ~200 ps from optical pumping, (d) after ~1 ps from optical pumping.

Fig. 8. Calculated *ac* conductivity for various pumping intensities at 300K. The vertical scale is normalized to the characteristic conductivity $e^2/2\hbar$.

Fig. 9. Crystal properties of the fabricated heteroepitaxial graphene on silicon sample. Upper: photo and micro-zoom images, middle: TEM image, bottom: Raman spectra at D, G, and G' band.

Figure 10. Measurement setup for optical-pump/THz-and-optical-probe spectroscopy. A CdTe crystal on top of the graphene sample generates the THz probe pulse and electro-optically detects the THz electric field intensity.

Fig. 11. Temporal (autocorrelation) and spectral profiles of pumping laser beam for two pulse compression conditions used in this experiment. Dotted line denotes the dynamic conductivity normalized to the characteristic conductivity $e^2/2\hbar$ at a pumping intensity of twice the threshold intensity at 300 K calculated using Eqs. (1)-(3). Shaded area denotes negative dynamic conductivity.

Fig. 12. Measured field emission properties (inset: temporal responses; main plot: Fourier spectrum) when the THz prove beam is generated by optical rectification of pumping photons in CdTe. Dashed line is the photoemission spectrum predicted from the pumping laser spectrum. (a)

Pumping with wider pulses (narrower spectrum) plotted with red curves in Fig. 11, and (b) pumping with shorter pulses (wider spectrum) plotted with black curves in Fig. 11.



Fig. 2.





Mercury lamp

Fig. 4.



Fig. 5.



Fig. 6.



(a)



(b)





Fig. 8.





Fig. 10.



Fig. 11.



Fig. 12.



(b)